

■ Development Project of “**New Mo Precursors**” Ver.2

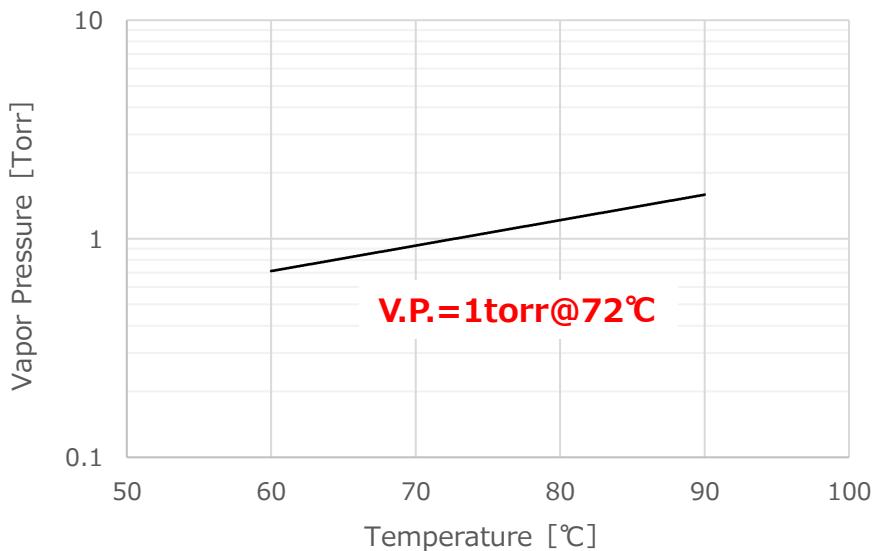
□ Target

- MoO_x
- Mo_xN_y
- Mo metal

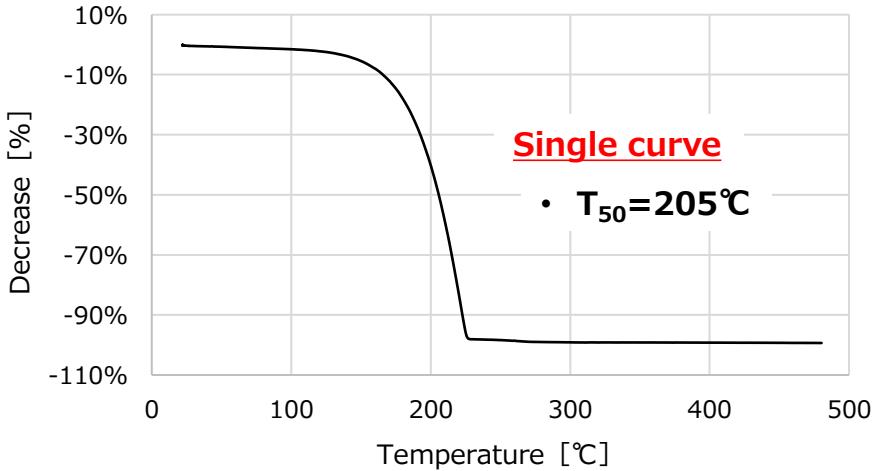
□ New Mo Precursor

- Code Name : [TCMo-19](#)
- Physical State : [Liquid](#)

[V.P. curve]



[TG-DTA]

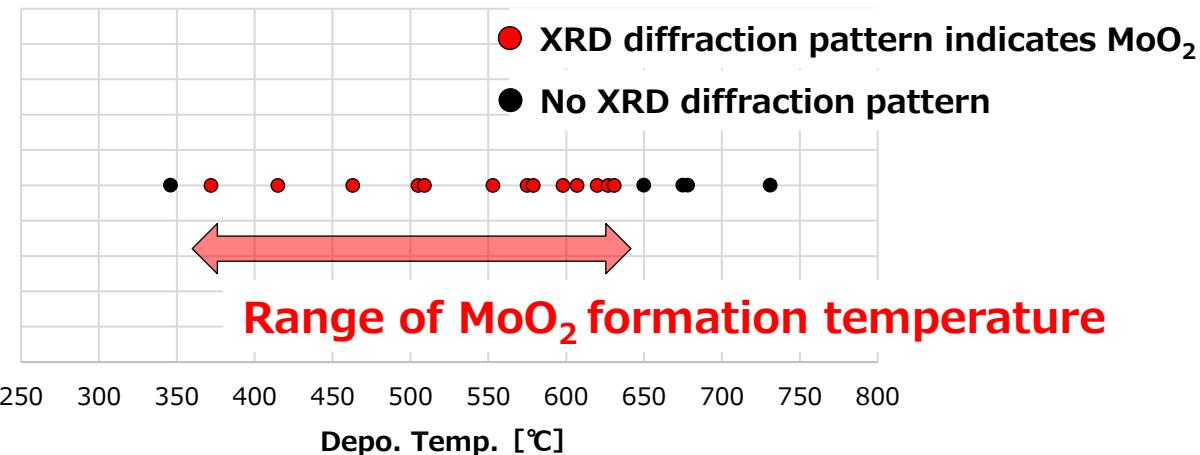
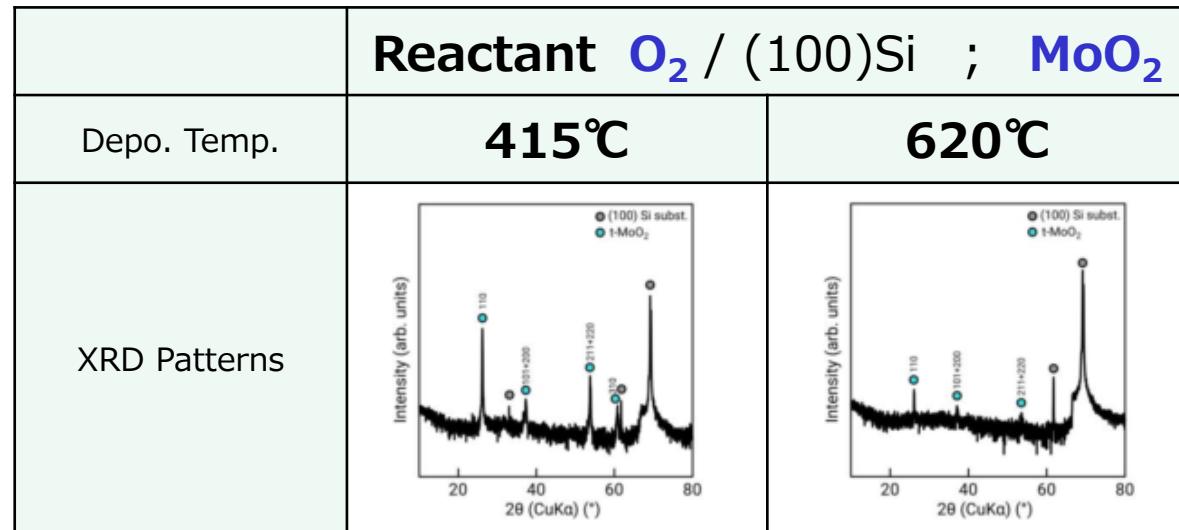


■ Collaboration “YNU A.ITO Laboratory”

□ Result (1)

- Laser CVD
- MoO₂

[Comparison of Deposition Temperature]

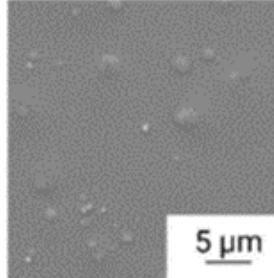
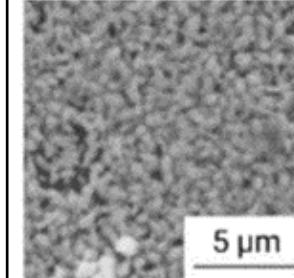


■ Collaboration “YNU A.ITO Laboratory”

□ Result (2)

- Laser CVD
- MoO₃

[Comparison of before and after annealing]

	As Depo.	<u>After annealed</u>
Condition	375°C / 10min	600°C / 3hr
Composition	MoO ₂	MoO ₃
Surface SEM image	 5 μm	 5 μm

[XRD]

